

Appl. No. 10/789,706  
Amdt. Dated , 2004  
Reply to Office Action of Sep. 9, 2004

### **Amendments to the Claims**

This listing of claims will replace all prior versions, and listings, of claims in the application:

### **Listing of Claims:**

Claim 1 (currently amended): A method for coating photoresist on a substrate, comprising the steps of:

forming grooves on the substrate;  
applying photoresist on the substrate; and  
vibrating the substrate in horizontal directions.

Claim 2 (original): The method for coating photoresist as claimed in claim 1, wherein the grooves are contiguous and parallel to each other.

Claim 3 (currently amended): The method for coating photoresist as claimed in claim [[1]] 2, wherein each of the grooves has a triangular cross section.

Claim 4 (original): The method for coating photoresist as claimed in claim 1, wherein the photoresist is sprayed onto the substrate.

Claim 5 (currently amended): The method for coating photoresist as claimed in claim [[1]] 4, wherein the photoresist is coated by one or more slit nozzles.

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Claim 6 (canceled)

Claim 7 (currently amended): The method for coating photoresist as claimed in claim 1, ~~wherein the substrate is vibrated in vertical directions~~ further comprising the step of vibrating the substrate in vertical directions after vibrating the substrate in horizontal directions.

Claim 8 (currently amended): A method for coating photoresist on a substrate, comprising the steps of:  
forming recesses on the substrate;  
applying photoresist on the substrate; and  
vibrating the substrate in horizontal directions so as to have the photoresist ~~occupies~~ occupying said recesses evenly.

Claim 9 (currently amended): The method for coating photoresist as claimed in claim 8, further comprising ~~[[a]]~~ the step of shaping a top portion of the photoresist with ~~[[an]]~~ a flat exterior surface.

Claim 10 (currently amended): A method for coating photoresist on a substrate, comprising the steps of:

- a) forming protrusions on the substrate;
- b) applying photoresist on the substrate; and
- c) vibrating the substrate in horizontal directions so as to have the photoresist covering the protrusions and portions beside said protrusions evenly.

Claim 11 (original): The method for coating photoresist as claimed in claim 10, wherein in step (b), a plurality of nozzles are respectively located

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right above apexes of the corresponding protrusions for spraying said photoresist.